### Microstructuring of bulk transparent solids using nanojoule femtosecond pulses

Chris B. Schaffer André Brodeur Nozomi Nishimura Eric Mazur

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## high intensity at focus...



Glezer, et al., Opt. Lett. 21, 2023 (1996)

### ... causes nonlinear ionization...



Glezer, et al., Opt. Lett. 21, 2023 (1996)

## and microscopic bulk damage



Glezer, et al., Opt. Lett. 21, 2023 (1996)

### and microscopic bulk damage



### with only tens of nanojoules!

## Outline

- Damage morphology
- Thresholds
- Ionization mechanisms









# how little energy produces permanent changes?

## Bring in pump beam...



## ... block probe beam...



## ... and detect light scattered by damage



### transmission of pump beam in fused silica



### transmission of pump beam in fused silica



### transmission of pump beam in fused silica



### vary numerical aperture in Corning 0211



## fit gives threshold intensity: $I_o = 2.7 \times 10^{17} \text{ W/m}^2$



### other materials...



### ... give other thresholds



### threshold increases with bandgap



## what do thresholds tell about ionization?



## laser field ionization



## laser field ionization



# impact ionization

![](_page_25_Figure_2.jpeg)

# impact ionization

![](_page_26_Figure_2.jpeg)

### threshold gives field ionization electron density

![](_page_27_Figure_2.jpeg)

### threshold gives field ionization electron density

![](_page_28_Figure_2.jpeg)

#### need critical electron density to damage

![](_page_29_Figure_2.jpeg)

### for low bandgap field ionization is sufficient

![](_page_30_Figure_2.jpeg)

### for high gap impact ionization required

![](_page_31_Figure_2.jpeg)

#### Summary

- damage with only nanojoules
- microstructuring without amplifiers
- transition from field to impact ionization

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For a copy of this talk and additional information, see:

http://mazur-www.harvard.edu